

DIGITAL IC DESIGN COMPLEMENTS AND ERRATA

This documents gathers complements of information to the course that results from issues and questions of general interest, as well as corrections to the course and exercises. Its most recent version is available for download from the Moodle web site of the course.

Thank you very much to all contributors who participate to the improvement of the course by their comments and corrections.

1. PRESENTATION TRANSPARENCIES

1.1 LECTURE L01

The PUN equation of Slide #29 is corrected as follows (this also applied to the slide used on the video).

$$f = (\bar{w} + \bar{x})(\bar{y} + \bar{z})$$

Also, some general explanations are provided in HW01 Solution, Ex. 1.1(b).

Slide #34 presents two examples of Shannon's expansion algorithm. The initial expression is expanded with respect to variable x and then is expanded with respect to variable y . In the following, both results that are derived from applying Shannon's expansion theorem are shown to be identical to the initial expression.

The derivation with respect to variable x yields

$$\begin{aligned} f(x, y, z) &= xy + yz + xz &= x(y + yz + z) + \bar{x}(yz) \\ & &= xy + xyz + xz + \bar{x}yz &(1) \\ & &= y[x(I + z)] + xz + \bar{x}yz &I + a = I \\ & &= xy + xz + \bar{x}yz \end{aligned}$$

This result which is shown in the slide is further manipulated using classical Boolean algebra in order to derive the initial expression. Starting from (1)

$$\begin{aligned} &xy + xyz + xz + \bar{x}yz \\ &= xy + yz(x + \bar{x}) + xz &a + \bar{a} = I \\ &= xy + yz + xz \end{aligned}$$

The derivation of Shannon's expansion with respect to variable y follows the same principle.

$$\begin{aligned} f(x, y, z) &= xy + yz + xz &= y(x + z + xz) + \bar{y}(xz) \\ & &= xy + yz + xyz + \bar{y}xz &(2) \\ & &= x[y(I + z)] + yz + \bar{y}xz \\ & &= xy + yz + \bar{y}xz \end{aligned}$$

From (2)

$$\begin{aligned} &xy + yz + xyz + \bar{y}xz \\ &= xy + yz + xz(y + \bar{y}) \\ &= xy + yz + xz \end{aligned}$$

1.2 LECTURE L02

On slide 79 of the video, the LDD is made as an implant of n- ("n-minus" not "n-plus") meaning that the intensity of doping and thus density of dopants is "small/light" whereas n+ determines a "strong/heavy" doping.

The Damascene process is used in modern deep-submicron fabrication techniques that use copper as the metal layer. It is considered easier since the contact/via and the metal are processed in one step (one single etching required for both).

2. EXERCISES

(none)